

Amendments

In the Title:

Please amend the title of invention to read – Liquid Crystal Display Having Black Matrix and Method for Fabricating The Same –.

In the Specification:

On page 1, line 3, please insert the following paragraph.

– This is a continuation application of the U.S. Patent Application Serial No. 09/853,642 filed May 14, 2001. –

Claims

Please **CANCEL** claims 1-25.

Please **ADD** claims 26-34, as follows.

1-25. (Cancelled)

26. (New) A liquid crystal display, comprising:
a first insulating substrate;
a black matrix formed on said first substrate, wherein the black matrix is mesh-shaped,
has opening portions at pixel areas and comprises a plurality of separated portions;
an insulating layer formed on and covering both said first substrate and said black matrix;

a gate line assembly formed on said insulating layer, said gate line assembly comprising gate lines proceeding in a horizontal direction, and gate electrodes connected to the gate lines;

a gate insulating pattern formed on and covering both said insulating layer and said gate line assembly;

a semiconductor pattern formed on said gate insulating pattern;

an ohmic contact layer formed on said semiconductor pattern;

a data line assembly formed on said ohmic contact layer, said data line assembly comprising a source electrode and a drain electrode separated from each other, and data lines connected to the source electrode while crossing over the gate lines to define the pixel areas; and

a protective layer covering said data line assembly and said gate line assembly while exposing said gate insulating pattern, said semiconductor pattern, and portions of said insulating layer placed at the pixel areas.

27. (New) The liquid crystal display of claim 26, further comprising a pixel electrode connected to the drain electrode, said protective layer having a first contact hole exposing the drain electrode, the connection of the pixel electrode to the drain electrode being made through the first contact hole.

28. (New) The liquid crystal display of claim 27, wherein the black matrix comprises a plurality of separated portions.

29. (New) The liquid crystal display of claim 28, wherein said black matrix comprises first portions overlapped with the gate lines, and second portions overlapped with the data lines, each buffer layer covering a gap between the separated portions neighboring each other.

30. (New) The liquid crystal display of claim 27, wherein each pixel electrode has a peripheral portion overlapping said black matrix.

31. (New) A method for fabricating a thin film transistor substrate for a liquid crystal display, comprising the steps of:

forming a black matrix on an insulating substrate, wherein the black matrix is mesh-shaped, has opening portions at pixel areas and comprises a plurality of separated portions;

forming an insulating layer on the substrate such that the insulating layer covers the black matrix;

forming a gate line assembly on the insulating layer, the gate line assembly comprising gate lines proceeding in a horizontal direction, and gate electrodes connected to the gate lines, wherein the gate lines are narrower than the black matrix;

depositing a gate insulating layer onto the insulating layer;

depositing a semiconductor layer onto the gate insulating layer;

forming an ohmic contact layer on the semiconductor layer;

forming a data line assembly on the ohmic contact layer, the data line assembly comprising a source electrode and a drain electrode separated from each other, and data lines connected to the source electrode while crossing over the gate lines to define the pixel areas, wherein the data lines are narrower than the black matrix;

depositing a protective layer onto the substrate such that the protective layer covers the data line assembly and the gate line assembly; and

forming opening portions exposing the insulating layer at the pixel areas through patterning the protective layer, the gate insulating layer and the semiconductor layer.

32. (New) The method of claim 31, further comprising the step of forming pixel electrodes such that the pixel electrodes are connected to the drain electrodes,

wherein the step of forming the opening portions comprising a step of forming first contact holes exposing the drain electrodes being formed at the protective layer, and

the pixel electrodes are connected to the drain electrodes through the first contact holes.

33. (New) The method of claim 32, wherein the black matrix comprises a plurality of separated portions.

34. (New) The method of claim 32, wherein each pixel electrode has a peripheral portion overlapping with the black matrix.